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POLYVINYL ALCOHOL-BASED COMPOSITION AND ITS PRODUCTION

Patent Number: JP9202843

Publication date: 1997-08-05

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Requested Patent: JP9202843

Application Number: JP19960010871 19960125

Priority Number (s):

IPC Classification: C08L29/04; C08L29/04; B32B27/20; B32B27/30; B65D81/24; C08F8/00; C08F8/42; C08F216/06; C08K3/36; C09D129/04

EC Classification:

Equivalents:

Abstract

PROBLEM TO BE SOLVED: To obtain the subject composition excellent in resistance to water and moisture, and capable of preserving high gas barrier property inherent in polyvinyl alcohol-based resin even if exposed to a highly humid atmosphere.

SOLUTION: This composition is such a one that an inorganic lamellar compound such as montmorillonite is located at voids in a crosslinked polymer consisting of a modified polyvinyl alcohol-based resin. The inorganic lamellar compound particles can be surely located at the voids of the crosslinked polymer by dissolving the crosslinked polymer in a solvent followed by adding the inorganic lamellar compound in the resultant solution.

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